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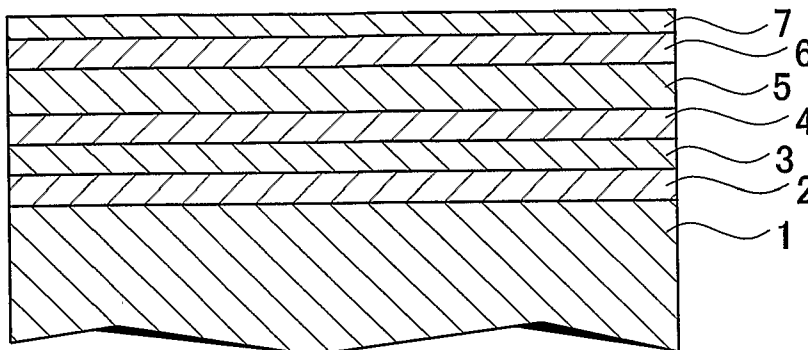
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[Continued on next page]

(54) Title: MAGNETIC RECORDING MEDIUM, METHOD OF MANUFACTURING THEREFOR, AND MAGNETIC READ/WRITE APPARATUS



(57) Abstract: A soft magnetic undercoat film, a first undercoat film, a second undercoat film, a perpendicular magnetic recording film, and a protective film are provided on a non-magnetic substrate, and the first undercoat film consists of Pt, Pd, or an alloy including at least one among these, and the second undercoat film consists of Ru or an Ru alloy.

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